



Spinning Disc Reactor: Basic Principles and Applications

Dr Kamelia Boodhoo

School of Chemical Engineering & Advanced Materials

Newcastle University

United Kingdom



Outline

- Operating Principles of SDR
 - Characteristic features of thin film flow
- Exploiting SDR characteristics: case studies of SDR application



Spinning Disc Reactors

Feed pipes



200 mm diam. smooth stainless steel disc

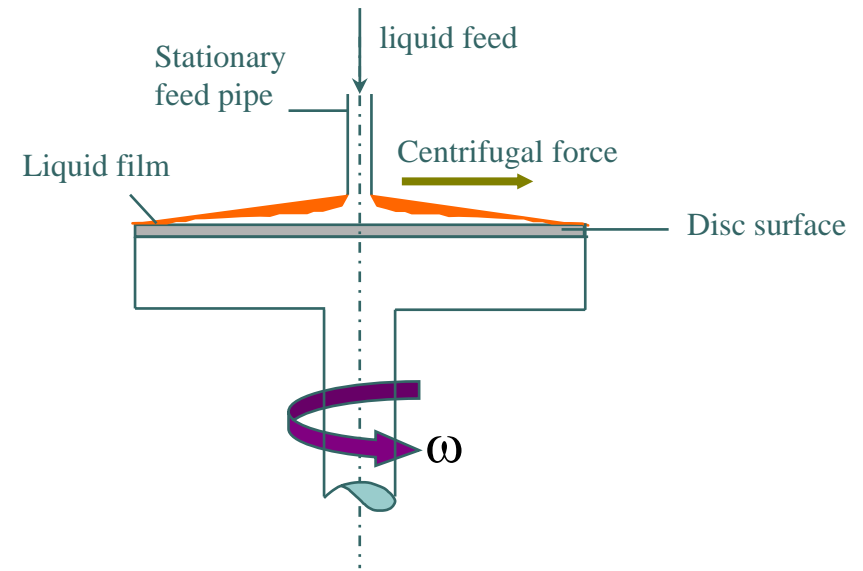
100 mm disc surface



Water cooled jacket

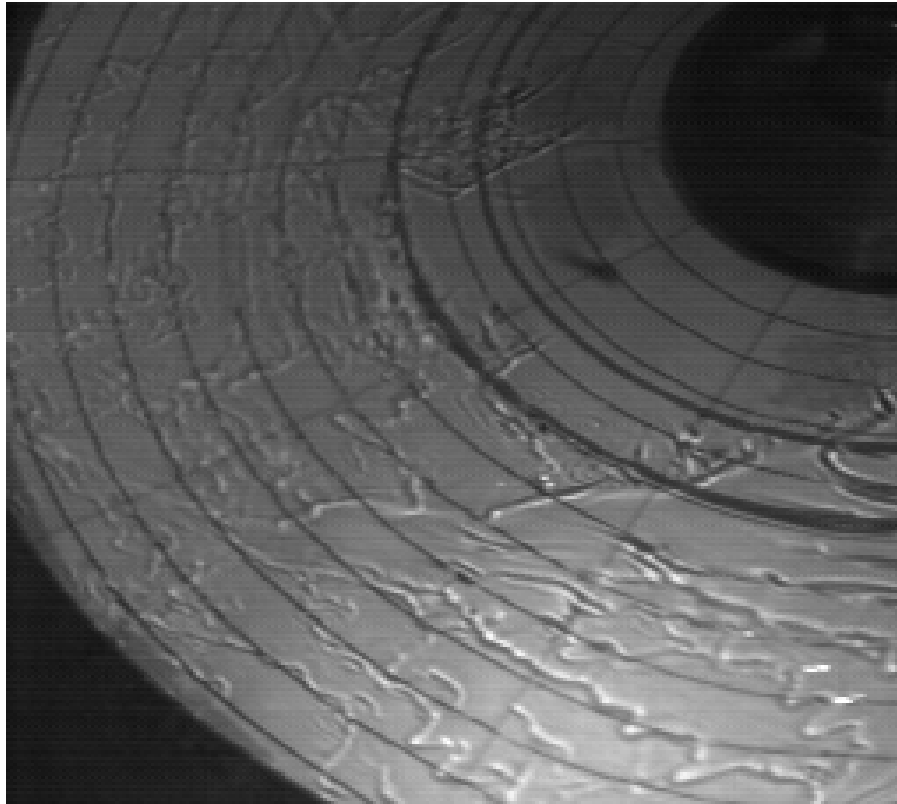
Characteristics features of SDR

- Rotation of disc surface creates high centrifugal fields which promote thin film flow
 - Centrifugal acceleration ($=\omega^2r$) as high as 1000g
 - Film thickness typically 50-500 μm
- Films are highly sheared and have numerous unstable surface ripples
- Various disc configurations may be used for enhanced performance
 - Smooth
 - Metal sprayed
 - Grooved





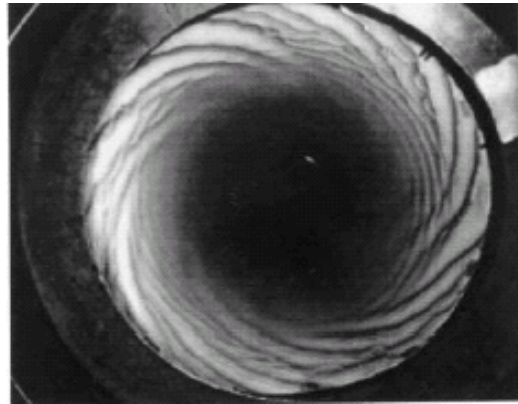
Thin film flow on a spinning disc



- Water like liquid on disc rotating at 400 rpm

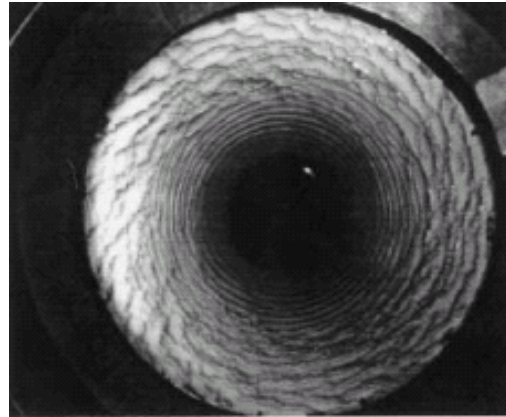
Wave formation in water-like fluid on rotating disc

Mass flowrate of liquid= 0.013-0.019 kg/s



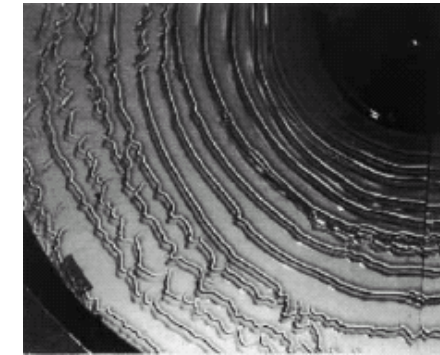
$\omega = 10 \text{ s}^{-1}$

Spiral waves

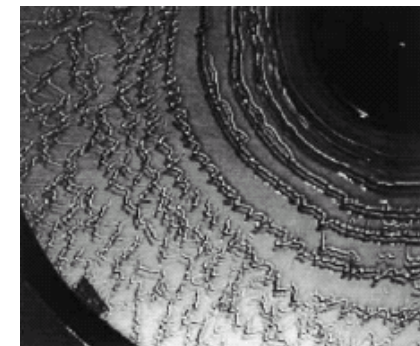
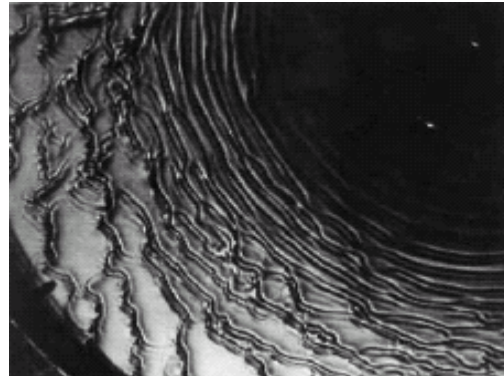
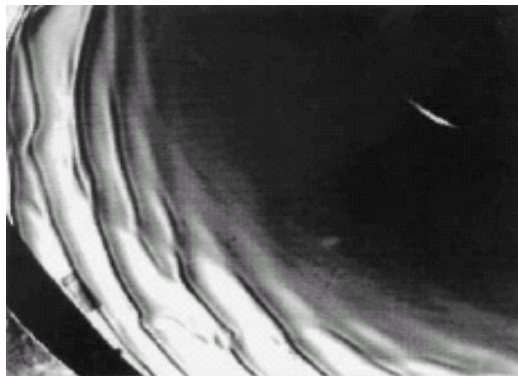


$\omega = 20 \text{ s}^{-1}$

Irregular surface ripples



$\omega = 40 \text{ s}^{-1}$



$\omega = 60 \text{ s}^{-1}$

(Source: Aoune & Ramshaw, *Int. J. Heat & Mass Transfer*, 42, 2543-2556 (1999))

Parameters of interest in SDR based on centrifugal model

Residence time: $t_{\text{res}} = \left(\frac{81 \pi^2 \nu}{16 \omega^2 Q^2} \right)^{1/3} \left(r_o^{4/3} - r_i^{4/3} \right)$

Film thickness: $\delta = \left(\frac{3 \nu Q}{2 \pi \omega^2 r^2} \right)^{1/3}$

Shear rate: $\dot{\gamma}_{\text{ave.}} = \left. \frac{dv_r}{dz} \right|_{z=0} = \frac{\omega^2 r \delta}{2\nu} = 1.5 \left(\frac{Q \omega^4 r}{18 \pi \nu^2} \right)^{1/3}$

where

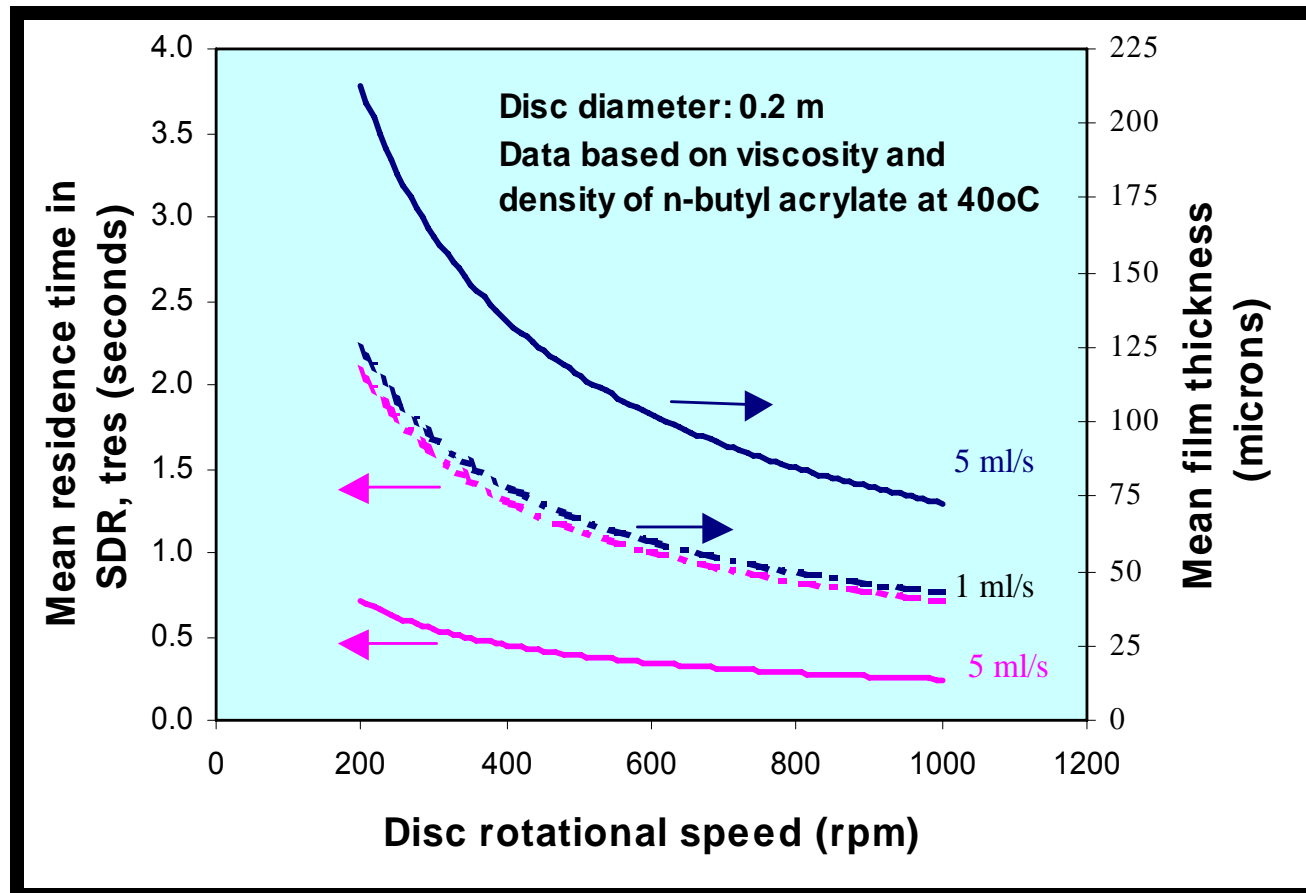
Q: feed flowrate

ν : kinematic viscosity ($=\eta/\rho$)

ω : rotational speed ($= 2\pi N/60$)

r: radial distance across disc surface

Mean residence time and film thickness profiles in SDR



● ● ● | Thin film flow regime in SDR

- Reynolds number:

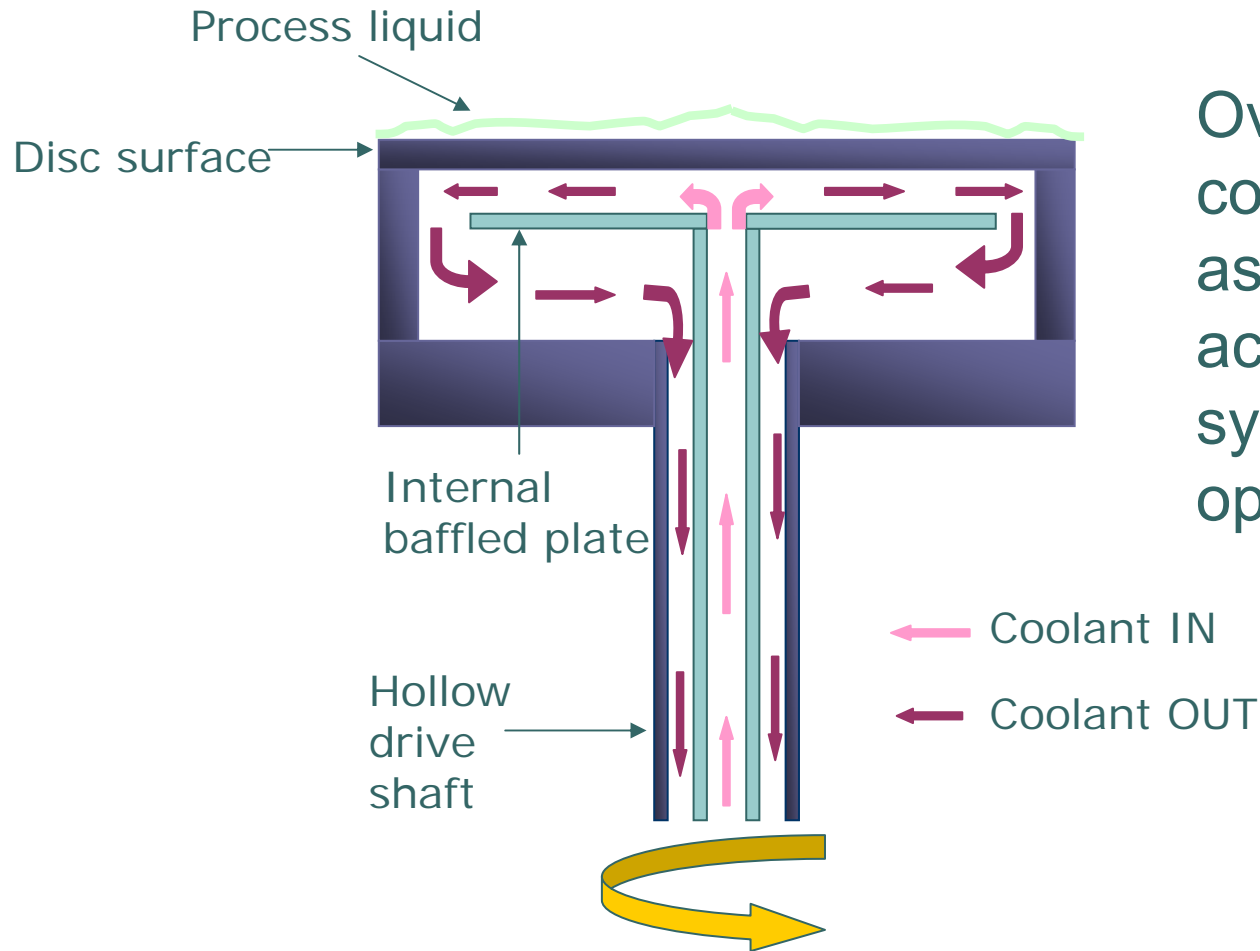
$$\text{Re} = \frac{4Q}{\pi v D}$$

- Various flow regimes observed:

- $\text{Re} < 16$: smooth laminar flow
- $16 \leq \text{Re} < 40$: Small amplitude waves
- $40 \leq \text{Re} < 80$: Sinusoidal and regular waves
- $\text{Re} > 80$: Random surface waves

- Waves greatly influenced by disc speed

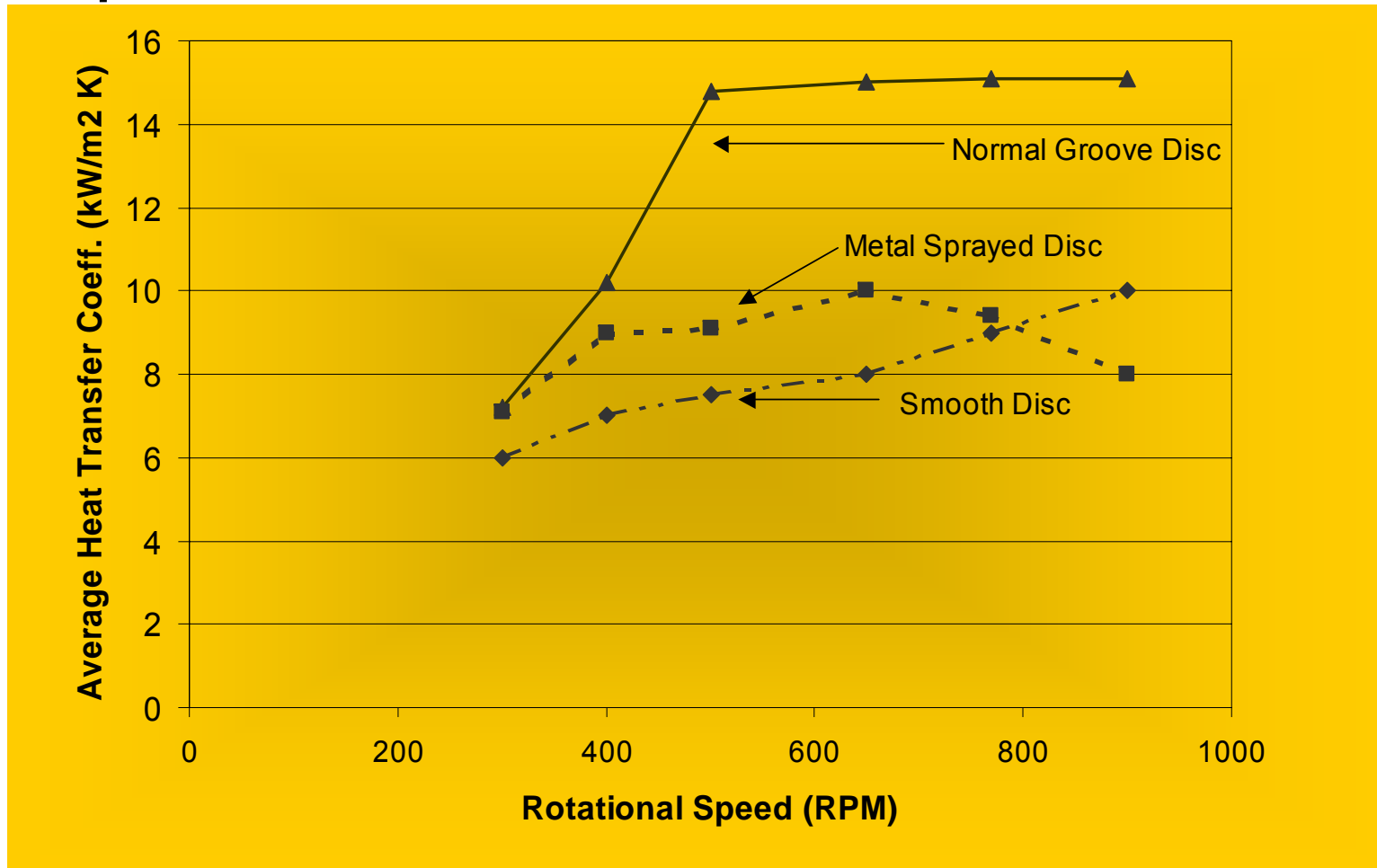
Heat transfer characteristics of thin film



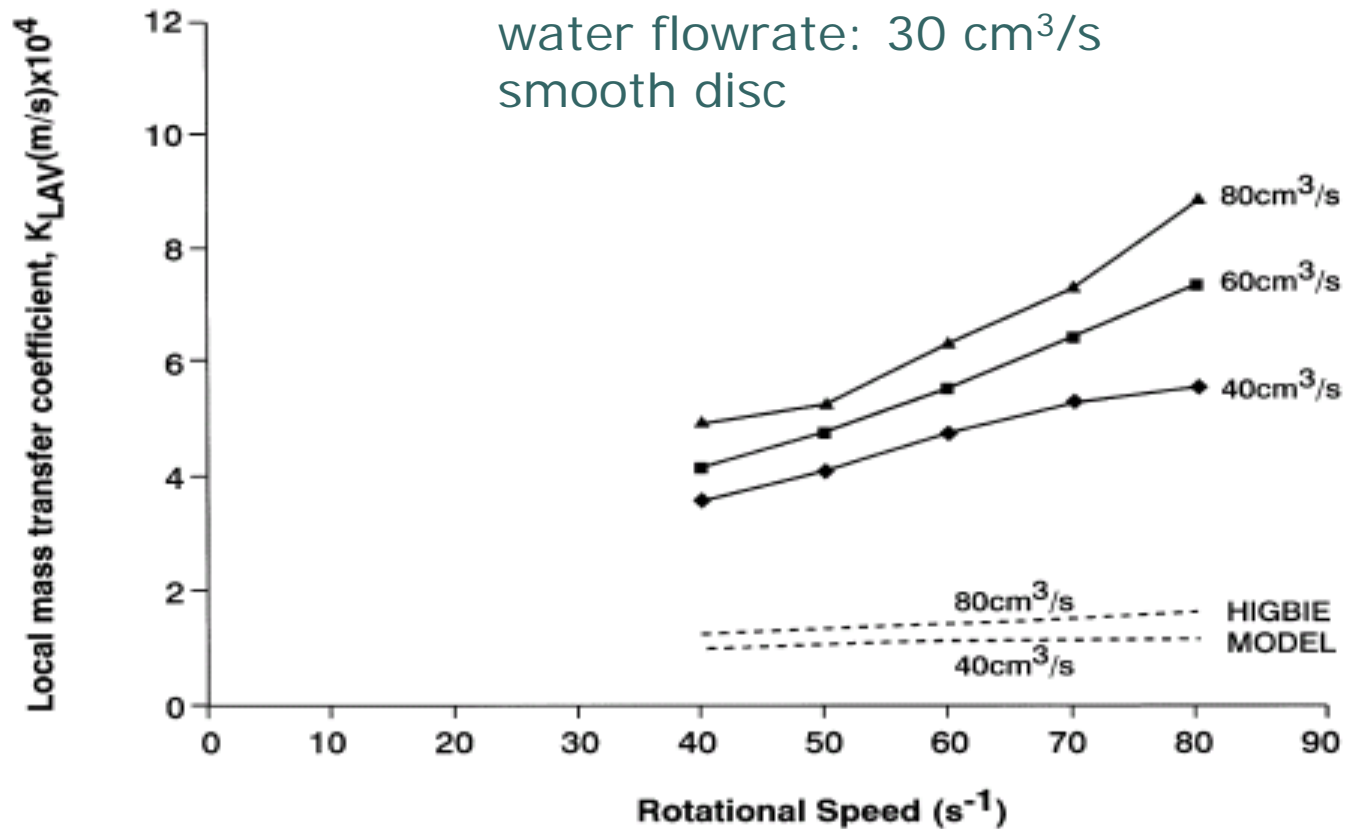
Overall heat transfer coefficient U as high as $4 \text{ kW/m}^2\text{K}$ can be achieved using this system under optimised conditions

Internal cooling/heating system in SDR

Convective heat transfer characteristics of films on rotating disc surfaces



Effect of rotational speed on local mass transfer coefficients in SDR film



(Source: Aoune & Ramshaw, *Int. J. Heat & Mass Transfer*, 42, 2543-2556 (1999))

Summary of characteristics of thin film flow in SDR

- Vigorous mixing characteristics at film surface (waves) and within film (high shear)
- High heat and mass transfer rates
- Short and easily controllable residence times
 - These characteristics make the SDR particularly suitable for reactions that are:
 - **Highly exothermic**
 - **Inherently fast**
- Extremely short path lengths for efficient UV penetration in photo-reactions

● ● ● | Reactions/processes for potential SDR application (1)

- Inherently fast, highly exothermic reactions
 - Acid-base neutralisation
 - Sulphonation
 - Polymerisations
 - Free-radical polymerisations
 - Chemical initiated
 - UV-initiated (photopolymerisation)
 - Cationic polymerisation
 - Step-growth polymerisations
 - Polyesterifications

● ● ● | Reactions/processes for potential SDR application (2)

- Reactions requiring rapid mixing
 - Crystallisations for narrow distribution of particle size
 - Organic, competitive reactions for high selectivity or high yield of desired product
- Processes involving heat sensitive materials
 - Polymer processing at high temperatures
 - Food processing
 - Short residence times in SDR gives minimal risk of degradation of product



Case study 1

SDR applications to mixing/mass transfer
limited processes in pharmaceutical
industry



Example 1: Phase transfer catalysed reaction- Darzen process

Rate limiting step: mass transfer across immiscible phases

	Batch Process	SDR process (4500 rpm)
Conversion	100%	90%
Reaction time	1 hr	<1 s
Reaction temp.	0°C	20°C
Impurity level	1.5%	0.1%
Reactor volume	100 (arbitrary units)	1
Production capacity	8 tonnes/yr	8 tonnes/yr

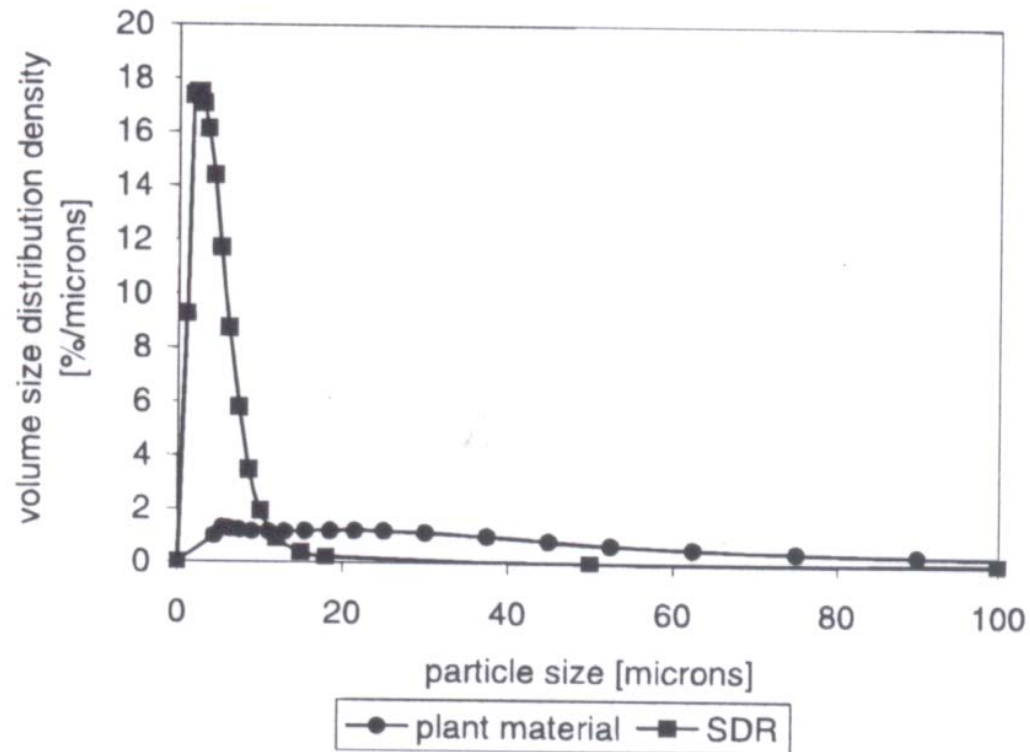
Source: Oxley, P. et al. "Evaluation of spinning disc reactor technology for the manufacture of pharmaceuticals", *Ind. Eng. Chem. Res.*, 39, 2175-2182 (2000)

● ● ● | Crystallisation in SDR

- Rapid micromixing in the SDR film at high supersaturation
- Homogeneous nucleation
- Smaller crystal sizes with tighter distribution

● ● ● | Example 2: Recrystallisation of an API

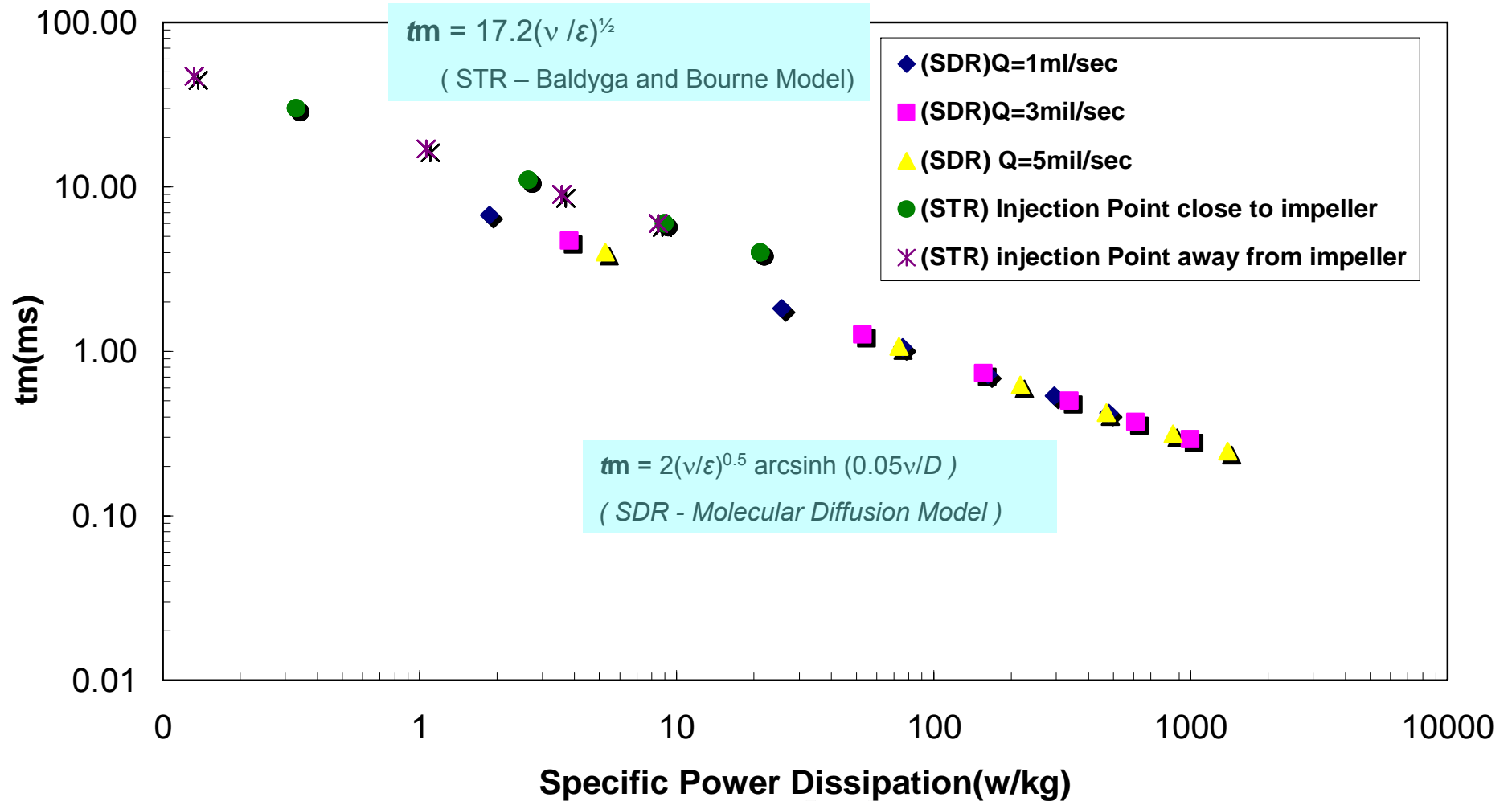
Rate limiting step: mixing (hence mass transfer)



Source: Oxley, P. et al. "Evaluation of spinning disc reactor technology for the manufacture of pharmaceuticals", *Ind. Eng. Chem. Res.* 39, 2175-2182 (2000)



Micromixing: SDR vs STR





Case study 2

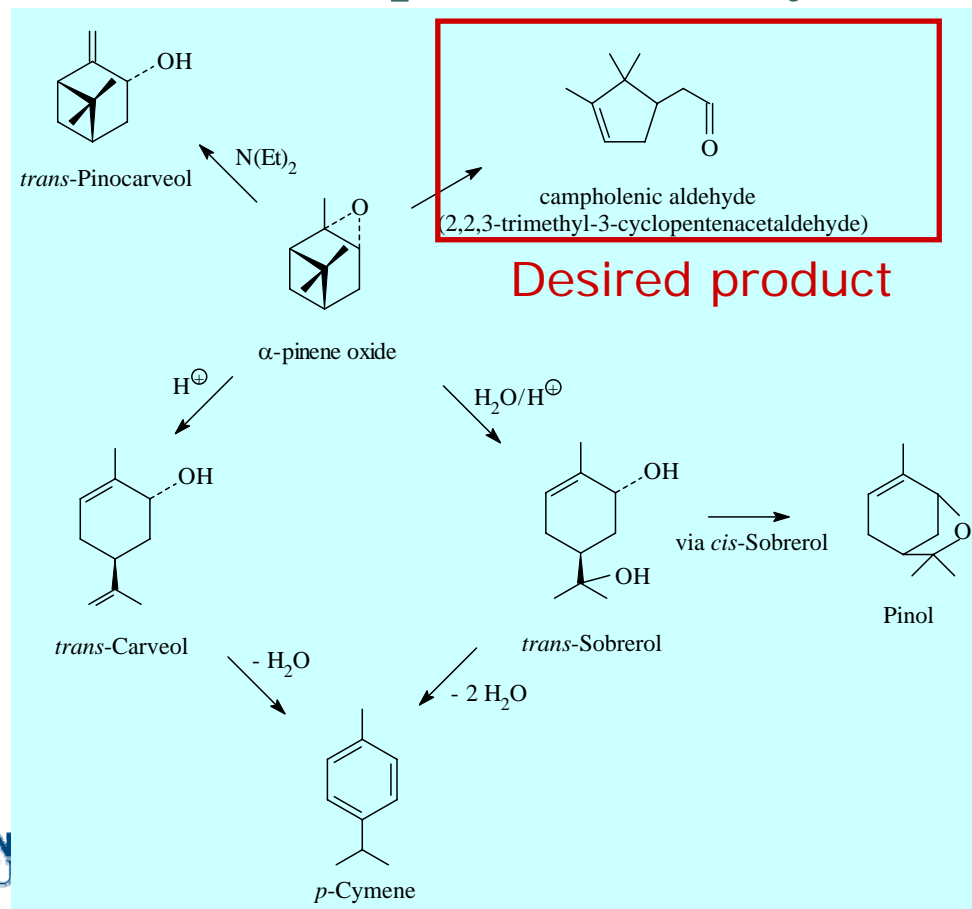
Application of SDR to organic catalytic reaction using immobilised catalyst

Process chemistry

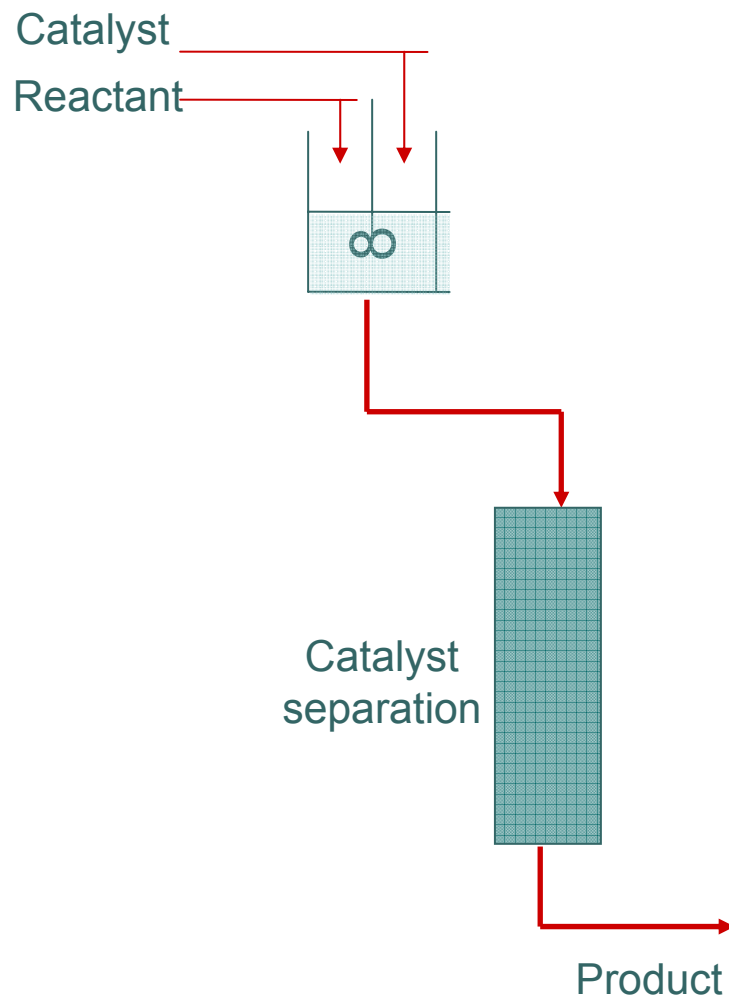


A – α -pinene oxide, B – campholenic aldehyde

- Homogeneous catalyst used in current industrial process
- Low selectivity due to many side reactions



Current industrial process

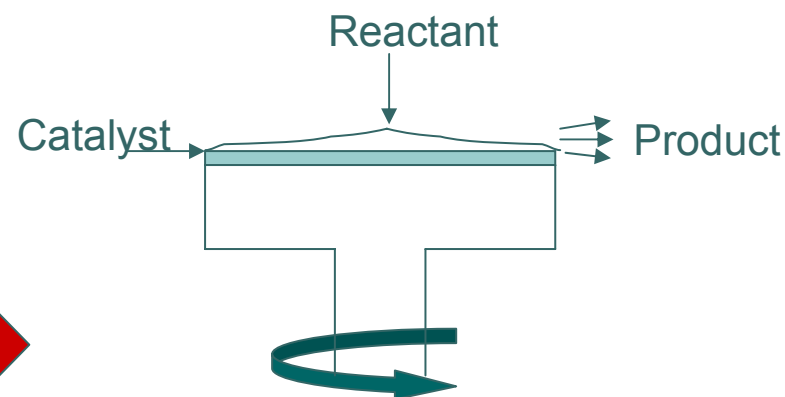


- Batch process where processing time is typically very high (order of hours)
- Need to separate catalyst from product using large amounts of solvent in downstream separation process
- Environmental considerations of waste disposal

Objectives of study

- Easier catalyst separation

- Development of heterogeneous catalysts
- Immobilisation on reactor surface
- Re-usable



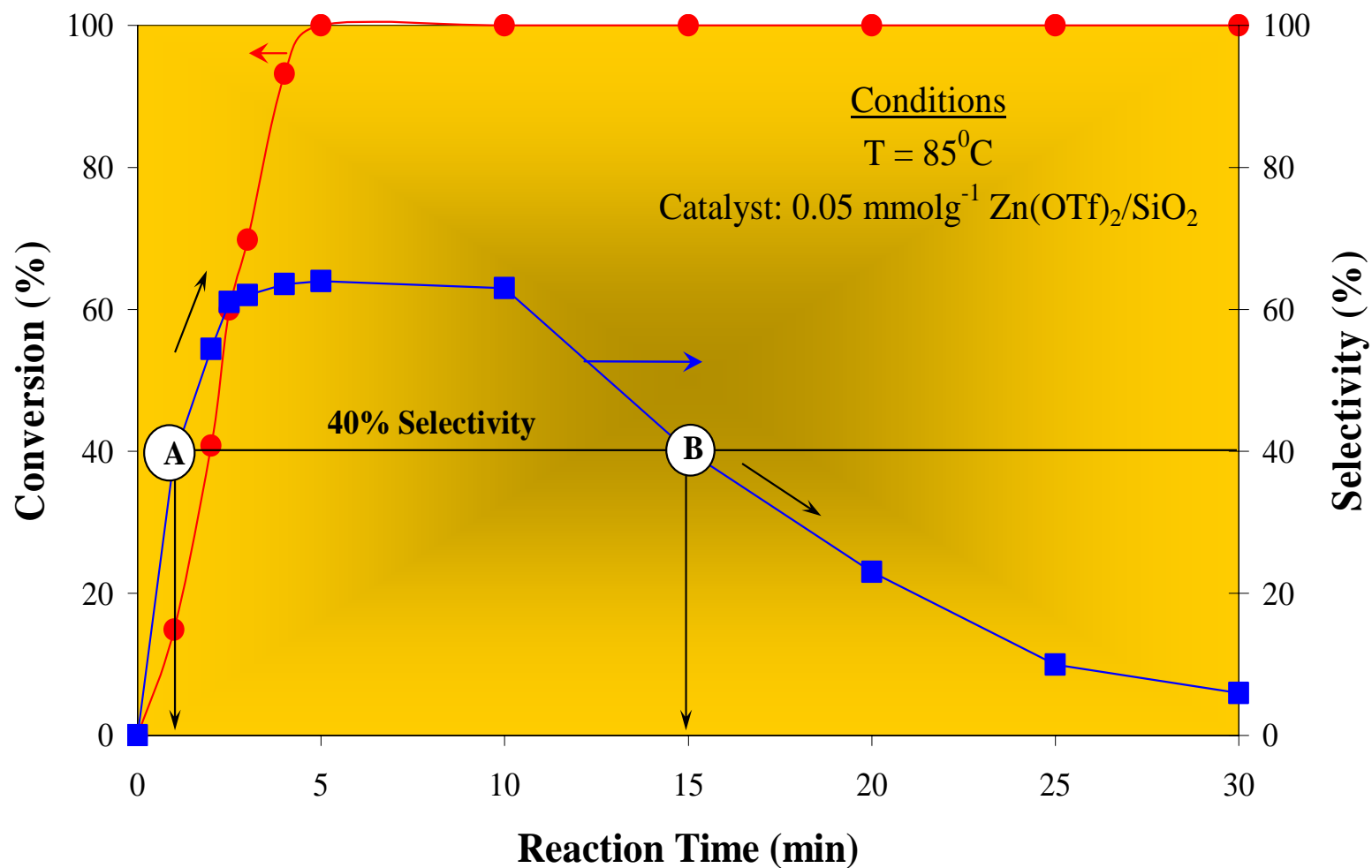
- Improve selectivity towards campholenic aldehyde using heterogeneous catalysis and intensified continuous processing

SDR processing:

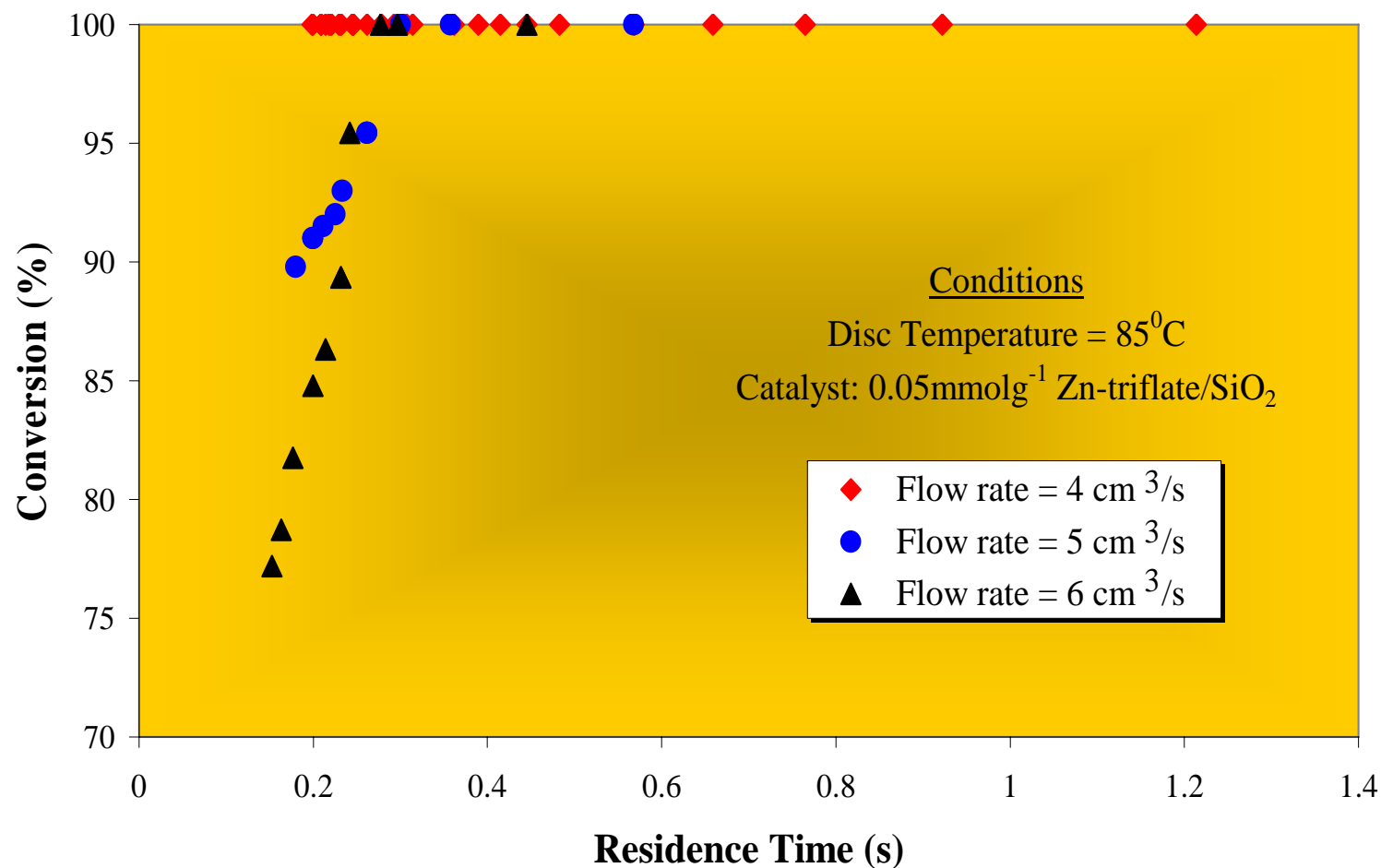
- Continuous process
- Processing time of the order of seconds
- Catalyst fixed to rotating surface



STR data for benchmarking

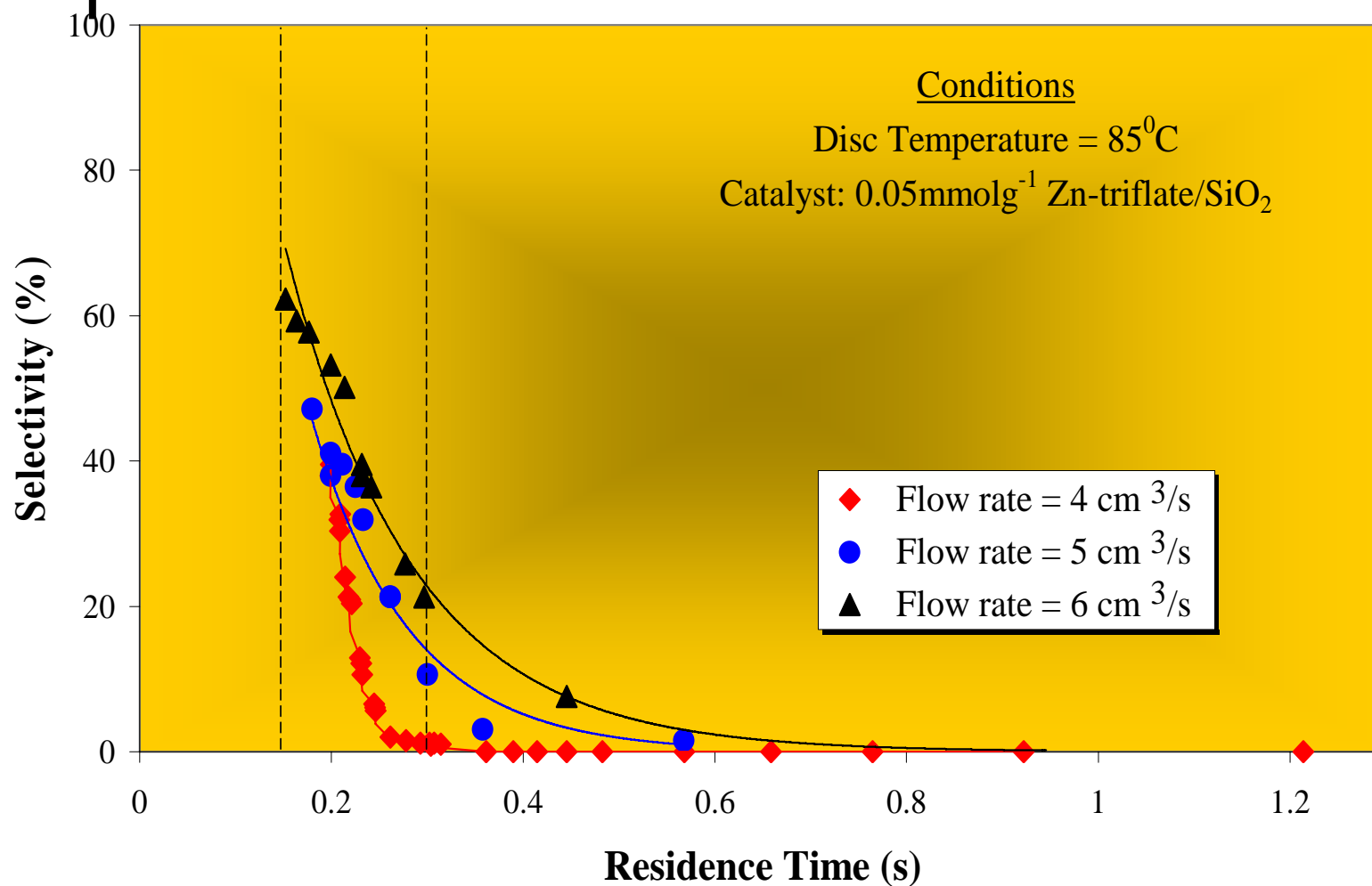


Effect of SDR residence time on conversion



M. Vicevic, K.V.K. Boodhoo and K. Scott, Catalytic Isomerisation of alpha-pinene oxide to campholenic aldehyde using silica supported zinc triflate catalysts: II. Performance of immobilised catalysts in a continuous Spinning Disc Reactor. *Chem. Eng. J.* **133**(1-3), 43-57 (2007).

Effect of SDR residence time on selectivity



M. Vicevic, K.V.K. Boodhoo and K. Scott, Catalytic Isomerisation of alpha-pinene oxide to campholenic aldehyde using silica supported zinc triflate: II. Performance of immobilised catalysts in a continuous Spinning Disc Reactor. *Chem. Eng. J.* **133** (1-3), 43-57 (2007).



Summary of results

- Reaction completed within 0.5 s in one SDR pass compared to a timescale of at least 5 min in the batch process
 - Improved mixing and mass transfer rates in the thin film formed on the rotating disc surface allows the catalytic reaction to proceed at its inherent rate in SDR
 - Reaction slower in batch due to mixing limitations
- High selectivity in the SDR is encouraged by the short and controllable residence times achieved on the disc
- High catalyst activity can be maintained in SDR over long periods of time as shown by re-use studies

Demonstrated benefits of SDR

- Faster reaction rates
 - Reduced processing time
- Improved product quality
 - Better control of molecular weight properties in polymerisations
 - Tighter particle size distribution in crystallisations
- Improved selectivity
 - Less unwanted by-products
 - Greener/cleaner technology since reduced downstream processing required
- Improved intrinsic safety
 - Low volumes of materials processed